



Process Research in Thin Film and Coating Technology

Guest Editors:

Dr. George D. Verros

Department of Chemistry,
Aristotle University of
Thessaloniki, P.O. Box 454
Plagiari Thes., 57500 Epanomi,
Greece

Dr. Raj Kumar Arya

Department of Chemical
Engineering, Dr. B.R. Ambedkar
National Institute of Technology,
Jalandhar 144011, India

Deadline for manuscript
submissions:

closed (25 June 2024)

Message from the Guest Editors

This Special Issue is dedicated to “Process Research in Thin Film and Coating Technology”. The aim is to bring together scientists working on the technology of membranes and coatings from several disciplines to further develop new methods and ideas.

The topics to be covered include (but are not limited to):

- Polymers, metals, alloys, and composites for membranes and coatings;
- Novel materials for membranes and coatings;
- Synthesis and characterization of membranes and coatings;
- Industrial processes;
- Thermodynamics and transport properties;
- Theory and simulations;
- Applications.





an Open Access Journal by MDPI

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank: CiteScore - Q2 (Chemical Engineering (miscellaneous))

Contact Us

Processes Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland

Tel: +41 61 683 77 34
www.mdpi.com

mdpi.com/journal/processes
processes@mdpi.com
[X@Processes_MDPI](https://twitter.com/Processes_MDPI)